



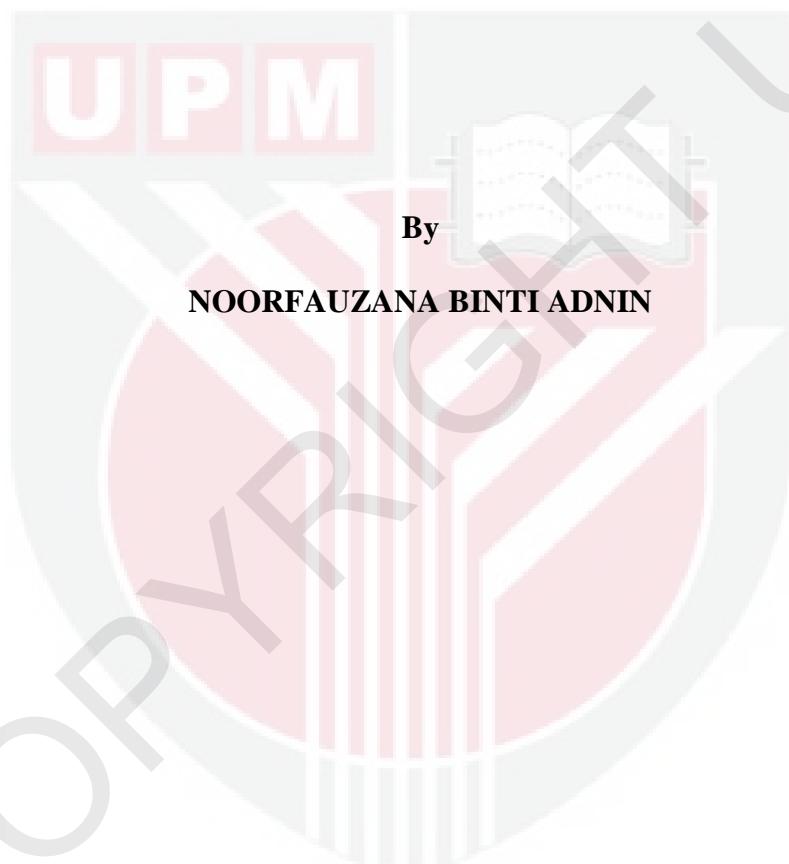
**UNIVERSITI PUTRA MALAYSIA**

**MICROSTRUCTURE AND ELECTRICAL AND OPTICAL  
PROPERTIES OF ZnO BASED VARISTOR CERAMICS WITH  
SMALL - AMOUNT OF MnO<sub>2</sub> AND Co<sub>3</sub>O<sub>4</sub> AS DOPANT**

**NOORFAUZANA BINTI ADNIN**

**FS 2012 17**

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**Thesis Submitted to the School of Graduate Studies Universiti Putra Malaysia  
in Fulfilment of the Requirements for the Degree of Master of Science**

**January 2012**

## DEDICATION

To my beloved family, supervisor and all my dearest friends.



Thanks for their guidance, supports, understanding, caring, love and encouragements.

May ALLAH bless us always.

Abstract of thesis presented to the Senate of Universiti Putra Malaysia in fulfilment  
of the requirement for the degree of Master of Science

**MICROSTRUCTURE AND ELECTRICAL AND OPTICAL PROPERTIES  
OF ZnO BASED VARISTOR CERAMICS WITH  
SMALL - AMOUNT OF MnO<sub>2</sub> AND Co<sub>3</sub>O<sub>4</sub> AS DOPANT**

By

**NOORFAUZANA BINTI ADNIN**

**January 2012**

**Chairman : Professor Azmi Zakaria, PhD**

**Faculty : Science**

Various stresses such as high electric fields, high temperature and aggressive ambient can inflict serious damages on machinery and other equipments and may degrade the performances of ZnO varistor devices. To develop a high performance of ZnO varistor ceramics, the influences of dopant are very crucial to be understood since dopants are responsible for the formation of varistor behavior. Therefore, small amount of MnO<sub>2</sub> and Co<sub>3</sub>O<sub>4</sub> as dopant is added to ZnO system respectively to improve the varistor properties. Although there were numerous studies on the effect of dopant on ZnO varistor, the exact roles of “small amount” dopant in ZnO varistor and how it can improve the nonlinear Current - Voltage (*I-V*) characteristics have not yet been clarified.

In this study, the microstructure, electrical and optical properties of the ZnO - xMnO<sub>2</sub> and ZnO - xCo<sub>3</sub>O<sub>4</sub> systems have been investigated for small amount of x ranging from 0.011 - 0.026 mol % at various sintering temperatures from 1180 - 1300 °C for the sintering time of 1 and 2 hours. XRD analysis shows that the main

phase was ZnO with  $\text{ZnMnO}_3$ ,  $\text{ZnMnO}_7$  and  $\text{Co}_3\text{O}_4$  as the secondary phases developed in the material systems. The maximum density have been achieved up to about 98% of theoretical density at 1300 °C sintering temperature at 0.011 mol % doping level of  $\text{Co}_3\text{O}_4$  and the relative density in general, has the value above 85%. The maximum grain size was found to be 14  $\mu\text{m}$  at the highest sintering temperature which is at 1300 °C at 0.021 mol % of  $\text{Co}_3\text{O}_4$  doping level. It was also found that  $\text{MnO}_2$  is a grain enhancer and promotes the grain growth of the ZnO samples. SEM and EDAX results verify that Mn and Co ions are distributed in the grain interior as well as in the grain boundaries. The value of nonlinear coefficient  $\alpha$ , is found to increase with the amount of  $\text{MnO}_2$  up to 0.016 mol% doping level, while slightly change with the amount for  $\text{Co}_3\text{O}_4$  mol%. Also, the value of nonlinear coefficient increases with the increase of sintering temperature and time for all ZnO system. An optimum sintering temperature of 1300 °C at 2 hour sintering time for  $\text{ZnO} + 0.016\%$   $\text{MnO}_2$  gave the best electrical properties, with the non-linear coefficient value  $\alpha$ , attaining a highest value of 9.11 in which represent fast response to transient voltage, thus give high protective function of ZnO varistor. The band gap energy  $E_g$ , decreases with the increase of  $\text{Co}_3\text{O}_4$  and  $\text{MnO}_2$  doping level and also sintering temperature respectively. For both dopants, the maximum decrease in the band gap occur at 0.026 mol % doping level at 1300 °C for 1 hour sintering time with the value of 2.65 and 2.46 respectively.

It is found that, the introduction of “small amount”  $\text{MnO}_2$  and  $\text{Co}_3\text{O}_4$  dopant influences the microstructure, electrical and optical properties of all ZnO systems. The electrical characteristics of all ZnO samples depend on their microstructure properties. For both dopant, the growth of interface states are responsible for the decrement of the energy band gap value.

Abstrak tesis yang dikemukakan kepada Senat Universiti Putra Malaysia sebagai memenuhi keperluan untuk ijazah Master Sains.

**PENCIRIAN STRUKTUR – MIKRO DAN ELEKTRIK DAN OPTIK  
VARISTOR SERAMIK BERASASKAN ZnO DENGAN KUANTITI SEDIKIT  
MnO<sub>2</sub> DAN Co<sub>3</sub>O<sub>4</sub> SEBAGAI BAHAN DOP**

Oleh

**NOORFAUZANA BINTI ADNIN**

**Januari 2012**

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Pelbagai tekanan seperti medan elektrik dan suhu yang tinggi serta persekitaran yang agresif boleh mengakibatkan kerosakan serius pada mesin dan peralatan - peralatan lain dan merosotkan prestasi peranti ZnO varistor. Untuk meningkatkan prestasi varistor seramik ZnO, pengaruh dopan adalah sangat penting untuk difahami dimana dopan bertanggungjawab terhadap pembentukan perilaku varistor. Oleh itu, MnO<sub>2</sub> dan Co<sub>3</sub>O<sub>4</sub> digunakan di dalam kuantiti yang sedikit sebagai bahan dop dimana setiap satu ditambah kepada sistem ZnO untuk meningkatkan sifat - sifat varistor. Walaupun terdapat banyak kajian mengenai kesan pendopan pada ZnO varistor, peranan sebenar bahan dop dalam “kuantiti sedikit” di dalam ZnO varistor dan bagaimana ia boleh meningkatkan sifat-sifat tak linear arus - voltan (*I-V*) masih belum dijelaskan secara terperinci.

Di dalam kajian ini, pencirian mikrostruktur, elektrik dan optik bagi sistem ZnO - xMnO<sub>2</sub> dan ZnO - xCo<sub>3</sub>O<sub>4</sub> telah dijalankan bagi perubahan nilai x dari 0.011 - 0.026 mol% pada pelbagai suhu pensinteran dari 1180 - 1300 °C dan dengan masa pensinteran selama 1 dan 2 jam. Analisis XRD menunjukkan bahawa fasa utama

adalah ZnO dengan  $ZnMnO_3$ ,  $ZnMnO_7$  dan  $Co_3O_4$  sebagai fasa - fasa kedua yang terbentuk di dalam sistem bahan. Ketumpatan maksimum telah dicapai sehingga 98% dari ketumpatan teori pada suhu pensinteran  $1300\text{ }^{\circ}\text{C}$  pada tahap 0.011 mol%  $Co_3O_4$  dan ketumpatan relatif secara umumnya mempunyai nilai di atas paras 85 %. Saiz butiran maksimum didapati adalah  $14\text{ }\mu\text{m}$  pada suhu pensinteran yang tertinggi iaitu  $1300\text{ }^{\circ}\text{C}$  pada tahap 0.021 mol%  $Co_3O_4$ . Didapati bahawa  $MnO_2$  adalah penggalak butiran dan menggalakkan pertumbuhan butiran sampel ZnO. Keputusan SEM dan EDAX menunjukkan bahawa ion Mn dan Co bertaburan di dalam butiran dan juga di sempadan butiran. Nilai pekali tak -linear,  $\alpha$  didapati meningkat dengan peningkatan jumlah  $MnO_2$  sehingga tahap 0.016 mol% manakala sedikit perubahan berlaku dengan peningkatan jumlah  $Co_3O_4$ . Nilai pekali tak-linear juga meningkat dengan peningkatan suhu dan masa pensinteran bagi kesemua sistem ZnO. Suhu persinteran yang optimum pada  $1300\text{ }^{\circ}\text{C}$  bagi masa persinteran selama 2 jam, memberikan sifat elektrik yang terbaik dengan nilai pekali tak-linear,  $\alpha$  mencapai nilai 9.11 yang mewakili tindakan pantas terhadap voltan fana, seterusnya melindungi ZnO varistor. Jurang jalur tenaga masing - masing menurun dengan peningkatan jumlah  $MnO_2$  dan  $Co_3O_4$  dan suhu persinteran. Bagi kedua - dua bahan dop, penurunan maksimum dalam jurang jalur berlaku pada tahap 0.026 mol% pada suhu pensinteran  $1300\text{ }^{\circ}\text{C}$  dan masa pensinteran selama 1 jam masing-masing dengan nilai 2.65 dan 2.46.

Didapati bahawa, bahan dop  $MnO_2$  and  $Co_3O_4$  di dalam kuantiti yang sedikit masing - masing mempengaruhi pencirian mikrostruktur, elektrik dan optik bagi kesemua sistem ZnO. Pencirian elektrik bagi kesemua sistem ZnO bergantung kepada pencirian struktur - mikro. Bagi kedua - dua bahan dop, pertumbuhan antara muka merupakan penyebab utama penurunan nilai jurang jalur tenaga.

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This thesis was submitted to the Senate of Universiti Putra Malaysia and has been accepted as fulfillment of the requirement for the degree of Master of Science. The members of the Supervisory Committee were as follows:

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**DECLARATION**

I declare that the thesis is my original work except for quotations and citations which have been duly acknowledged. I also declare that it has not been previously, and is not concurrently, submitted for any other degree at Universiti Putra Malaysia or other institutions.



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**NOORFAUZANA BINTI ADNIN**

Date: 18 January 2012

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